Supporting Information

Near-linear responsive and wide-range pressure and stretch sensor based on hierarchical graphene-based structures via solvent-free preparation

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Figure S1. Photos of resistance measurement of the graphene layer before and after smoothingwiping.



Figure S2. <u>Cross-sectional SEM images</u> of eross section of the _graphene layer before and after

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smoothing.





Figure <u>S2S4</u>. Radar <u>chartsplots</u> comparing <u>sensing</u> performance <u>between the SFG sensor and some</u>

related with graphene-based other sensors.1-5

Sampl e	Materials	Methods	Pressure sensitivity	Pressure respons e time	Strain Sensitivit y (GF)	Strain respons e time	Solvent
1 ⁶	SEBS/AgNPs	Electrospin ning (THF/DMF)	71.07kPa ⁻¹ (0.2~60 Pa); 7.38 kPa ⁻¹ (63~95 Pa)	<2 ms	/	/	DMF/T HF/Etha nol
27	MXenes/ tissue paper/ polylactic acid	Coating	0.55kPa ⁻¹ (23~982 Pa), 2.52 kPa ⁻¹ (10~30kPa)	11 ms	/	/	LiF/HCl
3 ⁸	MXene/textil e	Dip-coating	(29–40kPa); (29–40kPa); 3.844 kPa ⁻¹ (<29 kPa)	26 ms	/	/	HF/ Ethyl alcohol
4 ⁹	Carbon nanotube/ Ni- coated cotton yarn/ Polyurethane	Electrospin ning	16.52 N ⁻¹ (0.003–5N)	0.03 s	/	/	DMF/ THF/ Ethyl alcohol
5 ¹⁰	Silver nanowires /ZnO nanocrystals (NCs)	Chemical treatment	3.23 × 10 ³ kPa ⁻¹ (<10kPa); 3.46 × 10 ² kPa ⁻¹ (10~75kPa)	120ms	1	1	Toluene /Benzyl ether /Ethanol /Octade canol
6 ¹¹	PDMS / PET/ITO	Triboelectri c nanogenerat ors	0.136 kPa ⁻ 1(<110kPa)	< 9.9 ms	/	/	IPA
7 ¹²	SWCNTs/PD MS	Membrane transfer	0.59kPa ^{-1.} (~124 kPa)	/	0.68 (~300%)	/	Chlorof orm

TableS1 Comparison of SFG sensor and other pressure sensors

8 ¹³	Nylon fi ber/AgNWs/P DMS/Carbon black	Dip-coating	4.29 N ⁻¹ (0~0.2 N) 0.02 N ⁻¹ (0.2~2N)	8ms	(~100%)	/	Glycero l/Ethano l/Aceto ne/Chlo roform
9 ¹⁴	Poly(octamet hylene maleate (anhydride) citrate) (POMaC)/ Poly(glycerol sebacate) (PGS)/ Polylactic	Benchtop process	0.7±0.4 kPa-1 (<1 kPa); 0.13±0.03 kPa- 1 (5~10 kPa	Millisec ond range	0.5 (0– 15%)	Millisec ond range	1,8- octanedi ol/ Ethyl acetate
10 ¹⁵	acid Yarn/AgNW solution	Dip-coating	0.096 kPa ⁻¹ (< 0.1kPa) 1.1 MPa ⁻¹ (10 ~50 kPa)	32ms	3.2(<50%)	70ms	Ethylen e glycol
	Silver	Aerodynami					
11 ¹⁶	Nanoparticle/	cally Focused Nanoparticl	/	/	14		None
	Polyimide				(0.2~1%	/	
	(PI) film,)		
	PET	e					
12 ¹⁷	MWCNTs,/P olyimide tape	Adhesive	0.549 kPa ⁻¹ (<100kPa)	<32ms	/	/	None
13 ¹⁸	Indium Tin Oxide /PDMS	Sputter	0.21 kPa ⁻¹ (0~30Pa) 1.91kPa ⁻¹ (30~70kPa)	/	4000 (2%)	1ms	None
14 ¹⁹	Graphite/pape	Mechanical	4.77%/kPa	0.3ms	/	/	
	r	drawing	(<30kPa)				None
15 ²⁰	Cellulose/Pap	Mechanical	0.003kPa ⁻¹	/	/	/	None
	er/Graphene	drawing	(<45kPa)				

This work	Graphene nanosheets, PDMS	Electrostatic adsorption	1.37×10 ⁻³ kPa ⁻¹ (0 kPa to 50 kPa); 5.014×10 ⁻⁴ kPa ⁻¹ (50 kPa to 700 kPa)	10ms	36.2 (~30%)	12ms	None
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Figure S<u>5</u>4. <u>Waveform of one s</u>Single pulse signal. <u>waveform</u>



Figure S<u>65</u>. <u>Responsive s</u>Signal <u>response</u> diagram<u>s</u> for writing English letters on the <u>SFG</u> sensor.



Figure S76. (a) <u>CThe cross-sectional view of a SFGa</u> sensor-incorporating a PDMS protective

layer. (b,c) The SEM imagesdiagram of athe stretched SFG sensor stretched before coating without

PDMS protective film.

References for Supporting Information

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